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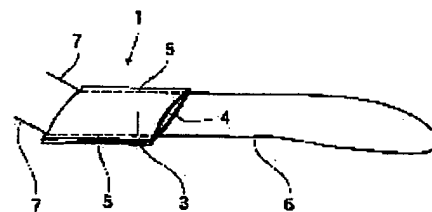
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(54) SUTURE PROSTHETIC MATERIAL

(57)Abstract:

PROBLEM TO BE SOLVED: To facilitate mounting and aligning and to prevent the mispositioning after mounting by forming a drawing part consisting of temporary sewing threads in a loop form on the rear side of a cylindrical suture prosthetic material formed by sewing a first cloth-like body consisting of in-vivo degradable absorptive stock and a second cloth-like body consisting of arbitrary stock by two temporary binding parts.

SOLUTION: The suture prosthetic material 1 is formed to a cylindrical shape by superposing the first cloth-like body 3 consisting of the in-vivo degradable absorptive stock and the second cloth-like body 4 consisting of the arbitrary stock on each other and forming the two temporary binding parts 5 with the temporary sewing threads 7 and is formed with the drawing part 6 consisting of the loop-like temporary sewing threads from one end (the rear side when the material is mounted on an automatic sewing device) of the suture prosthetic material. The drawing part 6 preferably allows the drawing manipulation of the temporary sewing threads at hand after operation. The length of the drawing part 6 is preferably a length which is about the same as the length of the arm part of the automatic sewing device or above. This suture prosthetic material is mounted on the staple receiving side of the automatic sewing device so as to cover the front end.



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